

Semiconductor Process Gases

All mixtures are Certified Master Class™.

ASML Lens Gases

Air Liquide provides a complete selection of photolithography lens gas mixtures suitable for ASML and other photolithographic lens systems.

| Concentration | Size | Contents | | Balance Gas | |
|-----------------------------------|------|----------|----------------|-------------|----------|
| | | CF | m ³ | Helium | Nitrogen |
| 1.2% He (ASML Grade) | 44P | 230 | 7 | | • |
| 0.52% N ₂ (ASML Grade) | 44P | 217 | 6 | • | |
| 0.5% O ₂ (ASML Grade) | 44P | 215 | 6 | • | |